

Attorney Docket No. 59521 (48229)

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

APPLICANT: Hiroyuki Shimada

EXAMINER: Chen Kin Chan

U.S.S.N.:

10/678,994

GROUP ART UNIT: 1765

FILED:

October 3, 2003

CONFIRMATION NO.: 8918

FOR: METHOD OF MANUFACTURING SEMICONDUCTOR DEVICE

INCLUDING ETCHING A CONDUCTIVE LAYER BY USING A GAS

INCLUDING SiCl4 and NF 3

CERTIFICATE OF EXPRESS MAILING (Label No.: EV 754865083 US)

I hereby certify that this correspondence is being deposited with the United States Postal Service "Express Mail Post Office to Addressee" service under 37 C.F.R. section 1.10, on <u>January 31, 2006</u> and is addressed to: Mail Stop AF, Commissioner for Patents, P.O. Box 1450, Arlington, VA 22313-1450.

Nicole M. McKinne

Mail Stop AF Commissioner for Patents P.O. Box 1450 Arlington, VA 22313-1450

Sir:

AMENDMENT AFTER FINAL

In response to the Office Action dated October 31, 2005, Applicant submits the following amendment.